



## UNITED STATE DEPARTMENT OF COMMERCE Patent and Trademark Office

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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR		ATTORNEY DOCKET NO.
09/207,972	12/09/98	GARDNER	iYi	5500-36100
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KEVIN L DAFFER CONLEY ROSE & TAYON P O BOX 398 AUSTIN TX 78767-0398 MMC2/0908 REXAMINER

WARREN, M

ART UNIT PAPER NUMBER

2815

DATE MAILED:

Please find below and/or attached an Office communication concerning this application or proceeding.

**Commissioner of Patents and Trademarks** 

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	Application No.	Applicant(s)						
Office Action Summary	09/207,972	GARDNER ET AL.						
omee Action Gammary	Examiner	Art Unit						
	Matthew E. Warren	2815						
The MAILING DATE of this communication appe Period for Reply	The MAILING DATE of this communication appears on the cover sheet with the correspondence address Period for Reply							
A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE $\underline{1}$ MONTH(S) FROM THE MAILING DATE OF THIS COMMUNICATION.								
<ul> <li>Extensions of time may be available under the provisions of 37 CFR 1.136 (a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailing date of this communication.</li> <li>If the period for reply specified above is less than thirty (30) days, a reply within the statutory minimum of thirty (30) days will be considered timely.</li> <li>If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication.</li> <li>Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133).</li> <li>Status</li> </ul>								
1) Responsive to communication(s) filed on 09 D	December 1998 .							
	s action is non-final.							
3) Since this application is in condition for allowa closed in accordance with the practice under the	nce except for formal matters, p							
Disposition of Claims		4.						
4) Claim(s) 1-22 is/are pending in the application.								
4a) Of the above claim(s) is/are withdraw	wn from consideration.							
5) Claim(s) is/are allowed.								
6) Claim(s) is/are rejected.								
7) Claim(s) is/are objected to.								
8) Claims 1-22 are subject to restriction and/or e	lection requirement.							
Application Papers	•							
9) The specification is objected to by the Examine	ır							
10) The drawing(s) filed on is/are objected to								
,	·	oround						
11) The proposed drawing correction filed on is: a) approved b) disapproved.								
12) The oath or declaration is objected to by the Ex	karılıler.							
Priority under 35 U.S.C. § 119								
13) Acknowledgment is made of a claim for foreign	priority under 35 U.S.C. § 119(a	a)-(d).						
a) ☐ All b) ☐ Some * c) ☐ None of the CERTIF	IED copies of the priority docum	ents have been:						
1. received.								
2. received in Application No. (Series Code / Serial Number)								
3. received in this National Stage application from the International Bureau (PCT Rule 17.2(a)).								
* See the attached detailed Office action for a list of the certified copies not received.								
14) Acknowledgement is made of a claim for domestic priority under 35 U.S.C. & 119(e).								
Attachment(s)		•						
<ul> <li>15) Notice of References Cited (PTO-892)</li> <li>16) Notice of Draftsperson's Patent Drawing Review (PTO-948)</li> <li>17) Information Disclosure Statement(s) (PTO-1449) Paper No(s) _</li> </ul>	19) 🔲 Notice of Informa	ry (PTO-413) Paper No(s) I Patent Application (PTO-152)						



Art Unit: 2815

## **DETAILED ACTION**

## Election/Restrictions

Restriction to one of the following inventions is required under 35 U.S.C. 121:

- Claims 16-22, drawn to a semiconductor device, classified in class 257, subclass 410.
- II. Claims 1-15, drawn to a method of making a semiconductor, classified in class 438, subclass 1+.

The inventions are distinct, each from the other because of the following reasons:

Inventions II and I are related as process of making and product made. The inventions are distinct if either or both of the following can be shown: (1) that the process as claimed can be used to make other and materially different product or (2) that the product as claimed can be made by another and materially different process (MPEP § 806.05(f)). In the instant case the silicon nitride layer could be sputtered onto the substrate instead of being formed by an annealing process.

Because these inventions are distinct for the reasons given above and the search required for Group I is not required for Group II, restriction for examination purposes as indicated is proper.

Applicant is advised that the reply to this requirement to be complete must include an election of the invention to be examined even though the requirement be traversed (37 CFR 1.143).



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Indexing Officer: AAHMED1 - ABDELLA AHMED

Team: OIPEBackFileIndexing

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No.	Doccode	Number of pages
1	A	1
2	CLM	1
3	REM	8

Total number of	pages:	10
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Remarks:

Order of re-scan issued on .....